

MgF₂

Fluoride MAGNESIUM SPUTTERING TARGET

Magnesium fluoride sputtering target is an inorganic compound with the formula MgF₂. The main application of magnesium fluoride is in optics, due to its distinctive transparency over a wide range of wavelengths. It is evaporated under vacuum to form anti-reflective layers.

Quick Facts

Product	:	Magnesium Fluoride Sputtering Target
Stock No	:	NS6130-10-1294
CAS	:	7783-40-6
Backing Plate	:	(As per Customer requirement)

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1294	99.99%	50.8 mm ± 1mm	3 mm ± 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Melting Point
MgF ₂	62.301g/mol	1263°C



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20ZICE4589C

19ZAZGO1274G

20ZICE4588M

High Purity
SPUTTERING
TARGET